



UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE
United States Patent and Trademark Office
Address: COMMISSIONER FOR PATENTS
P.O. Box 1450
Alexandria, Virginia 22313-1450
www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/601,980	06/23/2003	Bruce K. Wachtmann	2550/174	1368
2101	7590	09/07/2004		EXAMINER
BROMBERG & SUNSTEIN LLP				TRAN, LONG K
125 SUMMER STREET				
BOSTON, MA 02110-1618			ART UNIT	PAPER NUMBER
			2818	

DATE MAILED: 09/07/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary	Application No.	Applicant(s)	
	10/601,980	WACHTMANN ET AL.	
	Examiner	Art Unit	
	Long K. Tran	2818	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --
Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM
 THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) Responsive to communication(s) filed on 16 July 2004.
- 2a) This action is FINAL. 2b) This action is non-final.
- 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) Claim(s) 1- 20 is/are pending in the application.
- 4a) Of the above claim(s) 16 - 20 is/are withdrawn from consideration.
- 5) Claim(s) 9 - 15 is/are allowed.
- 6) Claim(s) 1-3 and 5-8 is/are rejected.
- 7) Claim(s) 4 is/are objected to.
- 8) Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) The specification is objected to by the Examiner.
- 10) The drawing(s) filed on _____ is/are: a) accepted or b) objected to by the Examiner.
 Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
 Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
 - a) All
 - b) Some *
 - c) None of:
 1. Certified copies of the priority documents have been received.
 2. Certified copies of the priority documents have been received in Application No. _____.
 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- 1) Notice of References Cited (PTO-892)
- 2) Notice of Draftsperson's Patent Drawing Review (PTO-948)
- 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)
 Paper No(s)/Mail Date 6/23/03.
- 4) Interview Summary (PTO-413)
 Paper No(s)/Mail Date. _____.
- 5) Notice of Informal Patent Application (PTO-152)
- 6) Other: _____.

DETAILED ACTION

Election/Restrictions

1. Applicant's election without traverse of **Group II (claims 1 – 15)** and withdrawn **Group I (claims 16 – 20)** in the reply filed on July 16, 2004 is acknowledged.

Information Disclosure Statement

2. This office acknowledges of the following items from the Applicant:

Information Disclosure Statement (IDS) filed on June 23, 2003.

The references cited on the PTO -1449 form have been considered Except the foreign document No. DE 19847455A1 (No English translation).

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

4. **Claims 1 – 3 and 5 – 8** are rejected under 35 U.S.C. 102(e) as being anticipated by Wachtmann et al. (US Patent Application Publication No. 2004/010444).

The applied reference has a common inventor with the instant application.

Based upon the earlier effective U.S. filing date of the reference, it constitutes prior art under 35 U.S.C. 102(e). This rejection under 35 U.S.C. 102(e) might be overcome either by a showing under 37 CFR 1.132 that any invention disclosed but not claimed in

the reference was derived from the inventor of this application and is thus not the invention "by another," or by an appropriate showing under 37 CFR 1.131.

Regarding claims **1** and **8**, Wachtmann et al. disclose method of forming a MEMS device, the method comprising: producing a device layer wafer 32 (figs. 3 – 8), wherein producing comprises: providing a material layer 32 (figs. 3 – 8); coupling a conductor 16 (figs. 3 – 8) to the material layer; and forming at least one conductive paths 24, 30 (figs. 3 – 8) through at least a portion of the material layer to the conductor; providing a handle wafer 36 (figs. 3 – 8); and coupling the produced device layer wafer to the handle wafer, the conductor being contained between the material layer and the handle wafer.

Regarding claim **2**, Wachtmann et al. disclose the material layer has an exposed top surface and conductive paths 24, 30 (figs. 6 – 8) extending to the exposed top surface.

Regarding claim **3**, Wachtmann et al. disclose removing a portion of the material layer to substantially expose the at least one conductive path [0034].

Regarding claim **5**, Wachtmann et al. disclose applying an insulator 34 (figs. 4 – 9) between the material layer and the conductor, the insulator coupling the conductor to the material layer.

Regarding claim **6**, Wachtmann et al. disclose the conductive path 24 is formed from a first semiconductor material (polysilicon [0027]) and the material layer is formed from a second semiconductor material (amorphous silicon [0026]).

Regarding claim 7, Wachtmann et al. disclose conductive path 30 is an anchor [0030].

Allowable Subject Matter

5. Claim 4 is objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

6. Claims 9 – 15 are allowed.

7. The following is an examiner's statement of reasons for allowance: Claims 4 and 9 – 15 are allowable over the prior art of record because none of the prior art whether taken singularly or in combination, especially when these limitations are considered within the specific combination claimed, to teach:

oxidizing an exposed top surface of a material layer 32 to optically distinguish the end of a conductive pathway 30 from the material layer as cited in claim 4 and independent claim 9; and among other limitations as cited in the independent claim 9.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Long K. Tran whose telephone number is 571-272-1797. The examiner can normally be reached on Mon-Thu.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms can be reached on 571-272-1787. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Long Tran 

August 31, 2004



David Nelms
Supervisory Patent Examiner
Technology Center 2800